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Dated: October 21, 2004

Signature: _____

(Michael R. Hill)

Docket No.: 30205/39509
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Cheol-Kyu Bok et al.

Application No.: 10/722,815

Art Unit: 1752

Filed: November 26, 2003

Examiner: Amanda C. Walke

For: **OVERCOATING COMPOSITION FOR
PHOTORESIST AND METHOD FOR
FORMING PHOTORESIST PATTERN USING
THE SAME**

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

Please enter the following amendment in the above-referenced patent application.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments in support of the allowability of this application begin on page 6 of this paper.